Case	8:16-cv-01721-CJC-KES Document 11	Filed 09/26/16	Page 1 of 13	Page ID #:32	
1	BRANDON C. FERNALD (BAR NO.	. 222429)			
2	BRANDON C. FERNALD (BAR NO. 222429) RACHEL D. STANGER (BAR NO. 200733) FERNALD LAW GROUP LLP 510 W. Sixth St. Suite 700				
3	510 W. Sixth St., Suite 700 Los Angeles, California 90014 Telephone: (323) 410-0300 Facsimile: (323) 410-0330				
4	E-Mail: brandon.fernald@fernaldlawgroup.com				
5					
6	DAVID A. SKEELS ( <i>Pro Hac App to be filed</i> ) DECKER A. CAMMACK ( <i>Pro Hac App to be filed</i> ) WHITAKER CHALK SWINDLE & SCHWARTZ PLLC				
7	301 Commerce Street, Suite 3500 Fort Worth, Texas 76102-4135				
8 9	Telephone: 817.878.0500 Facsimile: 817.878.0501				
9 10	Email: <u>dskeels@whitakerchalk.com</u> <u>dcammack@whitakerchalk.cor</u>	<u>n</u>			
11	Attomatic for Disintiff North Stor Inno	votions Inc			
12	Attorneys for Plaintiff North Star Inno	vations, me.			
13	IN THE UNITED OT A	TATES DIST	TES DISTRICT COURT TRICT OF CALIFORNIA		
14					
15					
16	NORTH STAR INNOVATIONS INC., Plaintiff,	C.,	Case No. 8:16-cv-01721		
17		Case No.			
18	V.	FIDG			
19 20	UMC GROUP USA AND CYPRESS SEMICONDUCTOR CORPORATION,		<b>FIRST AMENDED COMPLAINT FOR PATENT INFRINGEMENT</b> JURY TRIAL DEMANDED		
20		JURY			
21 22	Defendants.				
22					
23 24					
25		·			
26					
27					
28					

Plaintiff North Star Innovations Inc. ("Plaintiff" or "North Star"), by and
 through its attorneys, files this First Amended Complaint for Patent Infringement
 against Defendant UMC Group USA and Defendant Cypress Semiconductor
 Corporation. Plaintiff alleges as follows:

#### **PARTIES**

1. Plaintiff North Star is a corporation organized and existing under the laws of the State of Delaware, with a principal place of business at 600 Anton Blvd., Costa Mesa, California 92626. Plaintiff is the owner of seminal patents in various fields, including integrated circuits, semiconductor memory architecture, and semiconductor memory devices. Plaintiff's portfolio includes, for example, patents that teach valuable innovations and improvements related to semiconductor manufacturing processes and packaging, as well as patents that teach novel circuit designs to improve speed, power consumption, density, reliability, cost, efficiency, and organization. Plaintiff is actively engaged in licensing efforts with respect to such technologies.

2. Defendant UMC Group USA ("UMC USA") is a California corporation organized and existing under the laws of the State of California, with a principal place of business at 488 De Guigne Drive, Sunnyvale, CA 95124. UMC USA may be served by serving its registered agent for service of process, Mr. Peter Courture, 993 Highland Circle, Los Altos, CA 94024.

3. On information and belief, UMC USA is the U.S. and North American sales arm for, and a wholly-owned subsidiary of, United Microelectronics Corporation ("UMC"), a Taiwanese company that manufactures and sells semiconductor products throughout the world. *See, e.g.*, <u>http://www.umc.com/English/contact/index.asp</u>. UMC's website states: "UMC is a leading global semiconductor foundry that provides advanced technology and manufacturing for applications spanning every major sector of the IC [i.e., -1-

integrated circuit] industry. UMC's robust foundry solutions allow chip designers
 to leverage the company's leading-edge processes ... and a wide range of specialty
 technologies. Production is supported through 10 wafer manufacturing facilities ....
 The company employs over 17,000 people worldwide and has offices in Taiwan,
 Japan, Korea, China, Singapore, Europe, and the United States." UMC is a publicly
 traded entity in the United States, listed on the New York Stock Exchange under
 the ticker symbol of "UMC".

4. Defendant Cypress Semiconductor Corporation ("Cypress") is a
corporation organized and existing under the laws of the State of Delaware, with a
place of business at 198 Champion Ct., San Jose, CA 95134-1709. Defendant may
be served with process by serving its registered agent for service of process:
Corporation Service Company, 2710 Gateway Oaks Dr., Suite 150N, Sacramento,
California, 95833.

5. Cypress manufactures and sells various memory products, such as
SRAM, NOR Flash memories, and dual-port memories. On its website, Cypress
claims to be "the global leader in high-performance and low power memories [and]
No. 1 in SRAM market share," while Spansion, Inc. (which was recently merged
into Cypress) has long touted itself as "the world's leading manufacturer of NOR
Flash memory."

6. Joinder of both defendants in this action is proper under 35 U.S.C. §
299 because (a) Plaintiff asserts a right to relief against the defendants jointly,
severally, or in the alternative with respect to or arising out of the same transaction,
occurrence, or series of transactions or occurrences relating to the making, using,
importing into the U.S., offering for sale, or selling of the same accused product or
process, and (b) questions of fact common to all defendants will arise in this action.

26

1 2

3

4

5

#### JURISDICTION AND VENUE

7. This action arises under the patent laws of the United States, 35 U.S.C. § 1 *et seq.*, including §§ 271, 281, 282(a), 283, 284, and 285. This Court has subject matter jurisdiction over this patent infringement action pursuant to 28 U.S.C. §§ 1331 and 1338(a).

This Court has personal jurisdiction over Defendants. Defendants have 8. 6 7 regularly conducted and continue to conduct business in the State of California. On 8 information and belief, Defendants, directly or indirectly through their agents, have 9 committed infringing activities in California and in the United States by, at a 10 minimum, offering for sale and selling products that infringe the Patents-In-Suit (as 11 defined below); by placing such infringing products into the stream of commerce with the awareness, knowledge, and intent that they would be used, offered for sale, 12 13 and/or sold by others in this judicial district and/or purchased by consumers in this 14 judicial district; and/or by offering for sale and/or selling in this judicial district one 15 or more products made by a process patented in the U.S.

16

For example, according to the sworn declaration of UMC USA's 9. 17 General Manager, T.J. Lin, UMC USA: facilitates domestic (i.e., U.S.) contracts 18 between UMC and UMC's customers in the U.S. for the sale of wafers to such U.S. 19 customers (such as, for example, Cypress Semiconductor Corporation); provides 20 price quotations and other terms and conditions to U.S. customers; receives and 21 accepts purchase orders from U.S. customers; executes wafer supply agreements 22 with U.S. customers; invoices U.S. customers; collects payment from U.S. 23 customers; and retains at least some of the amounts collected from those U.S. 24 customers.

Further, this Court has personal jurisdiction over UMC USA because 25 10. 26 it is organized under the laws of the State of California and over Cypress because its principal place of business is here in California. Defendants have thereby availed 27

1 themselves of the privileges of conducting business in the State of California and 2 have sought protection and benefit from the laws of the State of California. This Court's exercise of personal jurisdiction over Defendants would therefore comport 3 4 with due process.

- 5
- 6

Venue is proper pursuant to 28 U.S.C. §§ 1391(b) and 1400(b). 11.

## THE PATENTS-IN-SUIT

7 12. On October 5, 1999, U.S. Patent No. 5,961,373 ("the '373 Patent") – 8 entitled "Process for Forming a Semiconductor Device" – was lawfully and properly issued by the United States Patent and Trademark Office ("USPTO"), after a full 9 10 and fair examination. The named inventors on the '373 Patent are Lei Ping Lai and 11 Sung C. Kim. A true and correct copy of the '373 Patent is attached hereto as Exhibit 12 A and incorporated by reference.

13 13. Generally speaking, the '373 Patent teaches, among other things, a Chemical Mechanical Polishing ("CMP") process in which conditioning of a 14 15 polishing pad is optimized to provide, among other benefits, a reproducible polishing process that reduces the likelihood of dishing and contributes to improved 16 17 planarity and greater efficiency.

18 14. On November 7, 2000, U.S. Patent No. 6,143,648 ("the '648 Patent") 19 - entitled "Method for Forming an Integrated Circuit" - was lawfully and properly 20 issued by the United States Patent and Trademark Office ("USPTO"), after a full 21 and fair examination. The named inventors on the '648 Patent are Robert Arthur 22 Rodriguez and Heather Marie Klesat. A true and correct copy of the '648 Patent is attached hereto as Exhibit B and incorporated by reference. 23

24 15. Generally speaking, the '648 Patent teaches, among other things, a 25 novel method for forming void-free plug contacts in which portions of the openings 26 are tapered.

1 16. On April 13, 1999, U.S. Patent No. 5,893,752 ("the '752 Patent") –
 entitled "Process for Forming a Semiconductor Device" – was lawfully and properly
 issued by the United States Patent and Trademark Office ("USPTO"), after a full
 and fair examination. The named inventors on the '752 Patent are Jiming Zhang and
 Dean J. Denning. A true and correct copy of the '648 Patent is attached hereto as
 Exhibit C and incorporated by reference.

- 17. Generally speaking, the '752 Patent teaches, among other things, a
  novel method for forming a semiconductor device having metal interconnects,
  which method, at least in certain embodiments, uses a first conductive film that
  includes tantalum and nitrogen and a second conductive film that includes mostly
  copper, to form a good barrier, to allow for better adhesion, to achieve better contact
  resistance, and to reduce the effects of electromigration.
- 13

14

18. The '373 Patent, the '648 Patent, and the '752 Patent may be referred to individually as a "Patent-in-Suit" or collectively as the "Patents-in-Suit."

15 19. By way of assignment, Plaintiff is the owner of all right, title, and
16 interest in and to the Patents-in-Suit, including the rights to prosecute this action
17 and to collect and receive damages for all past, present, and future infringements.

18

# **COUNT ONE: INFRINGEMENT OF THE '373 PATENT**

19 20. Plaintiff incorporates the above allegations as if set forth here in full.
20 21. The '373 Patent is valid and enforceable. UMC USA does not have a
21 license to practice the patented inventions of the '373 Patent.

22 22. On information and belief, at least Claims 1, 2, 3, and 10 of the '373 23 Patent are infringed when the CMP process is performed (a) on any patterned 24 semiconductor device substrate that includes an insulating layer and (b) by, and in 25 accordance with the recommended use of, certain (i) CMP polishing machines 26 manufactured and/or provided by Applied Materials, such as the AMAT Mirra 27 Polisher or the AMAT Reflexion Polisher, and (ii) pad conditioners, such as the 3M

28 DOCUMENT PREPARED ON RECYCLED PAPER

1 Diamond Pad Conditioner A165 or the K00003 Kinik pad conditioner. As described 2 herein, various products identified below include integrated circuits cut from UMC 3 wafers that (a) are, or include, patterned semiconductor device substrates that 4 include an insulating layer, and (b) have been subject to the CMP process as 5 described above, namely, by, and in accordance with the recommended use of, 6 certain (i) CMP polishing machines manufactured and/or provided by Applied 7 Materials, such as the AMAT Mirra Polisher or the AMAT Reflexion Polisher, and 8 (ii) pad conditioners, such as the 3M Diamond Pad Conditioner A165 or the K00003 9 Kinik pad conditioner.

10 23. On information and belief, and in violation of 35 U.S.C. §271(g), 11 UMC USA infringes at least Claims 1, 2, 3, and 10 of the '373 Patent. For example, 12 on information and belief, UMC USA offers for sale or sells products made 13 according to a process that meets every limitation in Claim 1 of the '373 Patent, 14 which recites: "A process for forming a semiconductor device comprising the steps 15 of: placing a substrate onto a polishing pad within an apparatus, wherein a layer 16 overlies the substrate; polishing the layer and conditioning the polishing pad using a first conditioner during a first time period; polishing the layer without 17 18 conditioning the polishing pad using the first conditioner for a second time period 19 after the first time period and before depositing an additional layer; and removing 20 the substrate from the apparatus after the steps of polishing."

24. On information and belief, many of the wafers manufactured by UMC pursuant to wafer supply agreements executed between UMC USA and U.S. customers, including wafers that are offered for sale and/or sold by UMC USA in the U.S. (in violation of 35 U.S.C. §271(g)), are manufactured at overseas foundries that own and utilize one or more Applied Materials Mirra and/or Reflexion Polishers, such as UMC Fab 12A in Tainan, Taiwan, UMC Fab 8D in Hsinchu, Taiwan, and UMC Fab 12i in Singapore.

28 Document Prepared on Recycled Paper 1 25. For example, UMC USA offers for sale and/or sells numerous 2 products manufactured at UMC Fab 12A, in violation of 35 U.S.C. §271(g). By way 3 of example, and on information and belief, the Cypress HX3 USB 3.0 HUB 4 Controller and Cypress' entire 16-MBIT Asynchronous SRAM Family (65nm) 5 include integrated circuits cut from wafers manufactured at UMC Fab 12A in 6 Tainan, Taiwan, using at least the process patented by Claim 1 of the '373 Patent. 7 On information and belief, UMC USA offers for sale and sells such wafers in the 8 U.S., in violation of 35 U.S.C.  $\S$  271(g).

9 26. UMC USA is and has been aware, since at least May 2016 if not
10 earlier, that integrated circuits cut from its infringing wafers are included in the
11 above-named products and that such products are offered for sale, sold, and/or used
12 within the United States.

13 27. On information and belief, there are additional products sold within 14 the U.S. that include integrated circuits cut from wafers offered for sale or sold by 15 UMC USA, and those wafers infringe because they are manufactured, in whole or 16 in part, using the patented processes recited in one or more claims of the '373 Patent, 17 in violation of 35 U.S.C. § 271(g). Plaintiff expressly reserves the right to assert 18 additional patents and additional claims and to identify additional infringing 19 products and additional entities who operate in concert with UMC USA, in 20 accordance with the Federal Rules of Civil Procedure, the Court's scheduling order 21 and the Court's local rules.

22 28. Plaintiff has been damaged by UMC USA's infringing conduct and 23 will continue to be damaged unless UMC USA is enjoined from further 24 infringement. Accordingly, upon finding for Plaintiff, the Court should award to 25 Plaintiff damages adequate to compensate for the infringement, in an amount to be 26 determined at trial, but in no event less than a reasonable royalty for the use made 27 of the invention by the infringer, together with interest and costs as fixed by the

28 Document Prepared on Recycled Paper Court. Further, upon judgment in favor of Plaintiff, the Court should permanently
 enjoin UMC USA from committing the infringing acts.

3

4

#### **COUNT TWO: INFRINGEMENT OF THE '648 PATENT**

29. Plaintiff incorporates the above allegations as if set forth here in full.

5 30. The '648 Patent is valid and enforceable. Defendants do not have a
6 license to practice the patented inventions of the '648 Patent.

7

8

31. On information and belief, and in violation of 35 U.S.C. §271(a) and/or (g), Defendants infringe at least Claim 9 of the '648 Patent.

9 32. For example, on information and belief, Cypress imports, offers to 10 sell, sells, and/or uses products, such as its 4Mb FAST Asynchronous SRAM, Part 11 No. CY7C1041G-10ZSXI ("FAST SRAM"), made by the novel process patented 12 by Claim 9 of the '648 Patent, which recites: "A method for forming an integrated 13 circuit, the method comprising: forming an opening in a surface of a semiconductor 14 substrate, the opening having a bottom portion, sidewall portions, and a top portion, 15 wherein the top portion includes a taper having dimensions that are wider towards 16 the surface of the semiconductor substrate and, narrower towards the sidewall portions; depositing a material over the surface of the semiconductor substrate and 17 18 within the opening; polishing away portions of the material over the surface of the 19 semiconductor substrate; and polishing away portions of the semiconductor 20 substrate to remove the top portion of the opening including the taper and portions 21 of the material contained within the top portion." In other words, the FAST SRAM 22 is made according to a process that performs each and every one of the above-23 referenced method steps. Cypress' actions in this regard violate 35 U.S.C. §271(a) 24 and (g).

25 33. Further, the above-referenced FAST SRAM is manufactured by UMC
26 in Tainan, Taiwan. On information and belief, UMC USA offers for sale and sells

such products in the U.S. to customers such as Cypress, in violation of 35 U.S.C.
 §271(g).

3 34. On information and belief, the patented method of Claim 9 of the '648
Patent is practiced in connection with the dual damascene integration schemes
present in various products and components made, imported, used, sold, or offered
for sale by Defendants. The importation, offer for sale, sale, or use of such products
by Defendants violates 35 U.S.C. § 271(a) and/or (g).

8 35. On information and belief, additional products of Defendants are, or 9 include components that are, manufactured using the patented methods recited in 10 one or more claims of the '648 Patent, and Defendants' conduct with respect to such 11 products violates at least 35 U.S.C. § 271(g). Plaintiff expressly reserves the right 12 to assert additional patents and additional claims and to identify additional 13 infringing products, in accordance with the Federal Rules of Civil Procedure, the 14 Court's scheduling order and the Court's local rules.

15 36. Plaintiff has been damaged by Defendants' infringing conduct and 16 will continue to be damaged unless Defendants are enjoined from further 17 infringement. Accordingly, upon finding for Plaintiff, the Court should award to 18 Plaintiff damages adequate to compensate for the infringement, in an amount to be 19 determined at trial, but in no event less than a reasonable royalty for the use made 20 of the invention by the infringer, together with interest and costs as fixed by the 21 Court. Further, upon judgment in favor of Plaintiff, the Court should permanently 22 enjoin Defendants from committing the infringing acts.

23

### **COUNT THREE: INFRINGEMENT OF THE '752 PATENT**

24 37. Plaintiff incorporates the above allegations as if set forth here in full.
25 38. The '752 Patent is valid and enforceable. Defendants do not have a
26 license to practice the patented inventions of the '752 Patent.

27

1 2

39. On information and belief, and in violation of 35 U.S.C. §271(a) and/or (g), Defendants infringe at least Claim 18 of the '752 Patent.

3 40. For example, on information and belief, Cypress imports, offers to 4 sell, sells, and/or uses products, such as its FAST SRAM, made by the novel process 5 patented by Claim 18 of the '752 Patent, which recites: "A process for forming a 6 semiconductor device comprising the steps of: forming a patterned insulating layer 7 over a substrate, wherein the patterned insulating layer includes an opening; 8 forming a first conductive film that includes tantalum and nitrogen, wherein: the 9 first conductive film includes a first portion and a second portion; the first portion 10 lies closer to the substrate and has a first nitrogen atomic percentage; and the second 11 portion lies further from the substrate and has a second nitrogen atomic percentage 12 that is lower than the first nitrogen atomic percentage; and forming a second 13 conductive film on the first conductive film, wherein the second conductive film 14 includes mostly copper; polishing the second conductive film to remove the second 15 conductive film overlying the patterned insulating layer outside of the opening; and 16 polishing the first conductive film to remove the first conductive film overlying the patterned insulating layer outside of the opening." In other words, the FAST SRAM 17 18 is made according to a process that performs each and every one of the above-19 referenced method steps. Cypress' actions in this regard violate 35 U.S.C. §271(a) and (g). 20

21 22 23

Further, the above-referenced FAST SRAM is manufactured by UMC 41. in Tainan, Taiwan. On information and belief, UMC USA offers for sale and sells such products in the U.S. to customers such as Cypress, in violation of 35 U.S.C. §271(g). 24

25 42. On information and belief, additional products of Defendants are, or 26 include components that are, manufactured using the patented methods recited in 27 one or more claims of the '752 Patent, and Defendants' conduct with respect to such

28 DOCUMENT PREPARED ON RECYCLED PAPER

products violates at least 35 U.S.C. § 271(g). Plaintiff expressly reserves the right
 to assert additional patents and additional claims and to identify additional
 infringing products, in accordance with the Federal Rules of Civil Procedure, the
 Court's scheduling order and the Court's local rules.

5 43. Plaintiff has been damaged by Defendants' infringing conduct and will continue to be damaged unless Defendants are enjoined from further 6 7 infringement. Accordingly, upon finding for Plaintiff, the Court should award to 8 Plaintiff damages adequate to compensate for the infringement, in an amount to be 9 determined at trial, but in no event less than a reasonable royalty for the use made 10 of the invention by the infringer, together with interest and costs as fixed by the 11 Court. Further, upon judgment in favor of Plaintiff, the Court should permanently enjoin Defendants from committing the infringing acts. 12

#### **DEMAND FOR JURY TRIAL**

44. Plaintiff hereby demands a trial by jury on all issues.

# PRAYER FOR RELIEF

WHEREFORE, Plaintiff respectfully prays for entry of judgment as follows:

17 1. That Defendants have directly infringed one or more claims of the18 Patents-in-Suit.

That Plaintiff is entitled to, and should recover, all damages to which
 Plaintiff is entitled under 35 U.S.C. § 284, but in no event less than a reasonable
 royalty;

3. That Defendants shall be permanently enjoined from furtherinfringement;

24

13

14

15

16

4. That Defendants be ordered to provide an accounting;

25 5. That Plaintiff, as the prevailing party, shall recover from Defendants all
26 taxable costs of court;

1	6. That Plaintiff shall recover from Defendants all pre- and post-judgment			
2	interest on the damages award, calculated at the highest interest rates allowed by law;			
3	7. That this case is exceptional and that Plaintiff therefore shall recover its			
4	attorney's fees and other recoverable expenses, under 35 U.S.C. § 285; and			
5	8. That Plaintiff shall recover from Defendants such other and further relief			
6	as the Court may deem appropriate.			
7				
8	DATED, Sentember 26, 2016 DDANDON C EEDNALD			
9	DATED: September 26, 2016 BRANDON C. FERNALD FERNALD LAW GROUP, LLP			
10				
11				
12	By: <u>/s Brandon C. Fernald</u> Brandon C. Fernald			
13				
14	Attorneys for Plaintiffs North Star Innovations, Inc.			
15	David A. Skeels			
16 17	Decker A. Cammack WHITAKER CHALK SWINDLE &			
17	SCHWARTZ PLLC 301 Commerce Street, Suite 3500			
19	Fort Worth, Texas 76102-4135 Telephone: 817.878.0500 Facsimile: 817.878.0501			
20	Facsimile: 817.878.0501			
21				
22				
23				
24				
25				
26				
27				
28	- 12 -			
PARED PAPER				

DOCUMENT PREPARED ON RECYCLED PAPER